

2D light emitting devices for silicon photonics

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Abstract

The missing piece of the jigsaw that is silicon photonics is a light source that can be easily incorporated into the standard silicon fabrication process. Molybdenum ditelluride (MoTe₂) is one of the most promising gain materials for this purpose [1], with monolayer MoTe₂ having a direct bandgap of 1.13 eV (i.e. emission wavelength at around 1130 nm at room temperature).

Here, I discuss our work using few-layer MoTe₂ and sandwiched MoTe₂ heterostructures as gain materials with silicon photonic crystal nanocavities. Firstly, we have demonstrated an optically pumped MoTe₂-on-silicon laser-like emitter, by employing an L3 photonic crystal cavity. This device operates at 1305 nm at room temperature, i.e. at the center of the "O-band" of optical communications, with a threshold power density of 1.5 kW/cm² [2]. More recently, we have demonstrated narrow emission from a sandwiched MoTe₂ heterostructure, consisting of a layer of MoTe₂ sandwiched between thin films of hexagonal boron nitride (hBN), on a silicon topological resonator [3]. The topological photonic crystal nanocavity laser design allows us to have better control on the cavity mode; as such we have demonstrated single mode operation at 1319 nm with a wide free spectral range. We have achieved a Q-factor of 4,500 with the active 2D heterostructure on cavity. These results lend further support to the paradigm of 2D material-based integrated light sources for silicon photonics platform. Finally, it is worth noting that the carrier mobility of MoTe₂ is several times larger than that of doped silicon, which makes this material suitable for electrical injection devices as we move into the future [4].

References

- [1] Y Li, J Zhang, D Huang, H Sun, F Fan, J Feng, Z Wang, C Z Ning, *Nature Nanotechnology* 12, (2017) 987;
- [2] H Fang, J Liu, H Li, L Zhou, L Liu, J Li, X Wang, TF Krauss, Y Wang, *Laser & Photonics Reviews* 12, (2018) 1800015;
- [3] H Fang, J Liu, Q Lin, R Su, Y Wei, TF Krauss, J Li, Y Wang, X Wang, *Advanced Optical Materials* 7, (2019) 1900538;
- [4] Y Bie, G Grosso, M Heuck, MM Furchi, Y Cao, J Zheng, D Bunandar, E Navarro-Moratalla, L Zhou, DK Efetov, T Taniguchi, K Watanabe, J Kong, D Englund and P Jarillo-Herrero, *Nature Nanotechnology* 12, (2017) 1124.